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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	
10/512,114	03/29/2005	Gabriele Korus	52201-0628 8401		
28481	7590 06/08/2006	EXAMINER			
	F & KELLY	HITESHEW, FELISA CARLA			
CHRYSLER BUILDING, 37TH FLOOR			ART UNIT	PAPER NUMBER	
405 LEXINGTON AVENUE NEW YORK, NY 10174			1722		

DATE MAILED: 06/08/2006

Please find below and/or attached an Office communication concerning this application or proceeding.

		Application	pplication No. Applicant(s)					
		10/512,11	4	KORUS ET AL.				
	Office Action Summary	Examiner	-	Art Unit				
		Felisa C. I		1722				
Period fo	The MAILING DATE of this communication appears on the cover sheet with the correspondence address Period for Reply							
A SHORTENED STATUTORY PERIOD FOR REPLY IS SET TO EXPIRE MONTH(S) OR THIRTY (30) DAYS, WHICHEVER IS LONGER, FROM THE MAILING DATE OF THIS COMMUNICATION.  - Extensions of time may be available under the provisions of 37 CFR 1.136(a). In no event, however, may a reply be timely filed after SIX (6) MONTHS from the mailing date of this communication.  - If NO period for reply is specified above, the maximum statutory period will apply and will expire SIX (6) MONTHS from the mailing date of this communication.  - Failure to reply within the set or extended period for reply will, by statute, cause the application to become ABANDONED (35 U.S.C. § 133). Any reply received by the Office later than three months after the mailing date of this communication, even if timely filed, may reduce any earned patent term adjustment. See 37 CFR 1.704(b).								
Status								
1)	Responsive to communication(s) filed on							
		—. nis action is n	on-final.					
	,	Since this application is in condition for allowance except for formal matters, prosecution as to the merits is						
/—	closed in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C.D. 11, 453 O.G. 213.							
Disposition of Claims								
4)⊠	Claim(s) <u>1-25</u> is/are pending in the applicatio	on.						
	4a) Of the above claim(s) is/are withdrawn from consideration.							
	☐ Claim(s) is/are allowed.							
·	☐ Claim(s) 1-25 is/are rejected.							
	Claim(s) is/are objected to.							
	Claim(s) are subject to restriction and	or election re	equirement.					
	on Papers							
	The specification is objected to by the Examir	nor						
			Objected to by the F	- - - -				
.0,	10) The drawing(s) filed on is/are: a) accepted or b) objected to by the Examiner.							
Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).								
Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d).  11) The oath or declaration is objected to by the Examiner. Note the attached Office Action or form PTO-152.								
Priority under 35 U.S.C. § 119								
_		,						
12) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).								
a) All b) Some * c) None of:								
	1. Certified copies of the priority documents have been received.							
2. Certified copies of the priority documents have been received in Application No								
3. Copies of the certified copies of the priority documents have been received in this National Stage								
application from the International Bureau (PCT Rule 17.2(a)).								
* See the attached detailed Office action for a list of the certified copies not received.								
Attachment(s)  1) Notice of References Cited (PTO-892)  4) Interview Summary (PTO-413)								
2) Notice of Draftsperson's Patent Drawing Review (PTO-948) Paper No(s)/Mail Date.								
3) 🛛 Inform	mation Disclosure Statement(s) (PTO-1449 or PTO/SB/08 r No(s)/Mail Date <u>see attached paper</u> .	8)	5) Notice of Informal Pa		O-152)			

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### **Priority**

1. Receipt is acknowledged of papers submitted under 35 U.S.C. 119(a)-(d), which papers have been placed of record in the file.

#### Information Disclosure Statement

The Information Disclosure Statement under 37 C.F.R. 1.97 has been received and reviewed. However, the information disclosure is not deemed to be pertinent over the prior art of record.

### Specification

# Content of Specification

- (a) <u>Title of the Invention</u>: See 37 CFR 1.72(a) and MPEP § 606. The title of the invention should be placed at the top of the first page of the specification unless the title is provided in an application data sheet. The title of the invention should be brief but technically accurate and descriptive; preferably from two to seven words may not contain more than 500 characters.
- (b) <u>Cross-References to Related Applications</u>: See 37 CFR 1.78 and MPEP § 201.11.
- (c) <u>Statement Regarding Federally Sponsored Research and Development:</u> See MPEP § 310.
- (d) <u>The Names Of The Parties To A Joint Research Agreement</u>: See 37 CFR 1.71(g).
- (e) Incorporation-By-Reference Of Material Submitted On a Compact Disc:
  The specification is required to include an incorporation-by-reference of electronic documents that are to become part of the permanent United States Patent and Trademark Office records in the file of a patent application. See 37 CFR 1.52(e) and MPEP § 608.05. Computer program listings (37 CFR 1.96(c)), "Sequence Listings" (37 CFR 1.821(c)), and tables having more than 50 pages of text were permitted as electronic documents on compact discs beginning on September 8, 2000.

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Or alternatively, Reference to a "Microfiche Appendix": See MPEP § 608.05(a). "Microfiche Appendices" were accepted by the Office until March 1, 2001.

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- (f) <u>Background of the Invention</u>: See MPEP § 608.01(c). The specification should set forth the Background of the Invention in two parts:
  - (1) Field of the Invention: A statement of the field of art to which the invention pertains. This statement may include a paraphrasing of the applicable U.S. patent classification definitions of the subject matter of the claimed invention. This item may also be titled "Technical Field."
  - (2) Description of the Related Art including information disclosed under 37 CFR 1.97 and 37 CFR 1.98: A description of the related art known to the applicant and including, if applicable, references to specific related art and problems involved in the prior art which are solved by the applicant's invention. This item may also be titled "Background Art."
- g) Brief Summary of the Invention: See MPEP § 608.01(d). A brief summary or general statement of the invention as set forth in 37 CFR 1.73. The summary is separate and distinct from the abstract and is directed toward the invention rather than the disclosure as a whole. The summary may point out the advantages of the invention or how it solves problems previously existent in the prior art (and preferably indicated in the Background of the Invention). In chemical cases it should point out in general terms the utility of the invention. If possible, the nature and gist of the invention or the inventive concept should be set forth. Objects of the invention should be treated briefly and only to the extent that they contribute to an understanding of the invention.
- (h) <u>Brief Description of the Several Views of the Drawing(s)</u>: See MPEP § 608.01(f). A reference to and brief description of the drawing(s) as set forth in 37 CFR 1.74.
- (i) Detailed Description of the Invention: See MPEP § 608.01(g). A description of the preferred embodiment(s) of the invention as required in 37 CFR 1.71. The description should be as short and specific as is necessary to describe the invention adequately and accurately. Where elements or groups of elements, compounds, and processes, which are conventional and generally widely known in the field of the invention described and their exact nature or type is not necessary for an understanding and use of the invention by a person skilled in the art, they should not be described in detail. However, where particularly

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complicated subject matter is involved or where the elements, compounds, or processes may not be commonly or widely known in the field, the specification should refer to another patent or readily available publication which adequately describes the subject matter.

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- (j) Claim or Claims: See 37 CFR 1.75 and MPEP § 608.01(m). The claim or claims must commence on separate sheet or electronic page (37 CFR 1.52(b)(3)). Where a claim sets forth a plurality of elements or steps, each element or step of the claim should be separated by a line indentation. There may be plural indentations to further segregate subcombinations or related steps. See 37 CFR 1.75 and MPEP § 608.01(i)-(p).
- (k) Abstract of the Disclosure: See MPEP § 608.01(f). A brief narrative of the disclosure as a whole in a single paragraph of 150 words or less commencing on a separate sheet following the claims. In an international application which has entered the national stage (37 CFR 1.491(b)), the applicant need not submit an abstract commencing on a separate sheet if an abstract was published with the international application under PCT Article 21. The abstract that appears on the cover page of the pamphlet published by the International Bureau (IB) of the World Intellectual Property Organization (WIPO) is the abstract that will be used by the USPTO. See MPEP § 1893.03(e).
- (I) Sequence Listing, See 37 CFR 1.821-1.825 and MPEP §§ 2421-2431. The requirement for a sequence listing applies to all sequences disclosed in a given application, whether the sequences are claimed or not. See MPEP § 2421.02.

# Claim Rejections - 35 USC § 112

- 2. Claim 1 recites the limitation "...cristobalite..." in line 5. There is insufficient antecedent basis for this limitation in the claim. Please insert the word –a—before the word "cristobalite" for proper antecedence.
- 3. Claim 13 recites the limitation "...opaque glass... in line 3. There is insufficient antecedent basis for this limitation in the claim. Please insert the word –a—before the words "opaque quartz" for proper antecedence.

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### Claim Rejections - 35 USC § 103

4. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

- (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 5. The factual inquiries set forth in *Graham* v. *John Deere Co.*, 383 U.S. 1, 148 USPQ 459 (1966), that are applied for establishing a background for determining obviousness under 35 U.S.C. 103(a) are summarized as follows:
  - 1. Determining the scope and contents of the prior art.
  - 2. Ascertaining the differences between the prior art and the claims at issue.
  - 3. Resolving the level of ordinary skill in the pertinent art.
  - 4. Considering objective evidence present in the application indicating obviousness or nonobviousness.
- 6. This application currently names joint inventors. In considering patentability of the claims under 35 U.S.C. 103(a), the examiner presumes that the subject matter of the various claims was commonly owned at the time any inventions covered therein were made absent any evidence to the contrary. Applicant is advised of the obligation under 37 CFR 1.56 to point out the inventor and invention dates of each claim that was not commonly owned at the time a later invention was made in order for the examiner to consider the applicability of 35 U.S.C. 103(c) and potential 35 U.S.C. 102(e), (f) or (g) prior art under 35 U.S.C. 103(a).
- 7. Claims 1-25 are rejected under 35 U.S.C. 103(a) as being unpatentable over Korus, et al '049 (U.S. Pat. No. 6,755,049 B2).

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Korus, et al '049 teaches a method for manufacturing a quartz glass crucible in which a crucible base body is provided at least in part with an inner layer in which the formation of cristobalite is induced by using a crystallization promoter. The crystallization promoter promotes the formation of cristobalite in the area of the inner wall when the quartz glass crucible is heated up again and, at the same time. contributes to the formation of the reducing substance which reduces the growth of bubbles by way of its "getter effect", thereby ensuring a firm adhesion of the cristobalite layer and thus a long service life of the quartz glass crucible. Either one and the same chemical as an element or in a chemical compound acts here as a crystallizationpromoting and bubble-reducing agent at the same time, i.e. simultaneously as a crystallization promoter and as a reducing substance, or a chemical compound is concerned of which one part acts as a crystallization promoter and another part as a reducing substance (see column 3, lines 22-40). In consideration of this additional condition, the reducing substance is preferably formed from an initial substance containing one or more of the elements titanium, tungsten, molybdenum, silicon, zirconium or a compound of said elements. Barium titanate (BaTiO3) or barium zirconate (BaZrO3) is used in a particularly preferred manner as initial substance for the reducing substance in a concentration between 0.003 mol% and 0.02 mol%. The indicated concentration refers to the concentration in the spreading material. Barium titanate or barium zirconate as reducing substances in the sense of the invention help not only to reduce bubbles, but also act as crystallization-promoting agents. Moreover, barium and titanium as well as zirconium are characterized by a relatively small

coefficient of distribution in silicon. Impurities in the SiO2 of the inner layer normally promote the formation of cristobalite, so that in the case of contaminated SiO2 a complete crystallization of the inner layer must already be expected at a BaTiO3 or BaZrO3 content of less than 0.003 mol% (column 4, lines 15-38).

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On the whole, the following metals are in particular expected to be suited as a reducing substance, coupled with a bubble-reducing getter effect: W, Mo, Ba, Ti, Ga, Ge, In, Sn, Tl, Pb, Zr, Si, alkaline-earth metals, rare-earth metals and Fe, and also chemical compounds having a per se reducing effect under the conditions of the crystal pulling process in the form of hydrides, nitrides, silicides. Chemical compound in the form of oxides, carbonates, titanates, zirconated, tungstates, molybdates, ferrates, cobaltates, nickelates, vanadates, niobates, tantalates and chomates are also suited under the precondition of the inner layer as initial substances for the formation of a reducing substance (see column 4, lines 62-68 and column 5, lines 1-7).

The difference being that Korus, et al '049 does not exactly teach a quartz crucible or a method of producing a quartz crucible, wherein the first component and the second component each have a distribution coefficient in silicon of  $10^{-5}$ , in a concentration ranging from 0.003 mol-% to 0.02 mol-% in the doping region. However, in the absence of unobvious results, it would have been obvious to one of ordinary skill in the art to modify and optimize the process and product parameter limitation in order to ensure proper orientation, since Korus, et al '049 does teach a network former (i.e. titanium (Ti) and zirconium (Zr)) along with an alkaki-metal free breakpoint former

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(i.e. barium (Ba) and gallium (Ga). The motivation being that a quartz glass crucible with reproducible characteristics for long serives lives can be manufactured.

A reference is good not only for what it teaches by direct anticipation but also for what one of ordinary skill might reasonably infer from the teachings. In re Opprect 12 USPQ 2d 1235, 1236 (CAFC 1989); In re Bode 193 USPQ 12; In re Lamberti 192 USPQ 278; In re Bozek 163 USPQ 545, 549 (CCPA 1969); In re Van Mater 144 USPQ 421; In re Jacoby 135 USPQ 317; In re LeGrice 133 USPQ 365; In re Preda 159 342 (CCPA 1968).

Expected beneficial results are evidence of obviousness, just as unexpected beneficial results are evidence of unobviousness. In re Novak 16 USPQ 2d 2041 (Fed. Cir., BPAI 1989); In re Hoffman 194 USPQ 126 (CCPA 1977); In re Skoll 187 USPQ 481 (CCPA 1975); In re Skoner 186 USPQ 80 (CCPA 1975); In re Garshon 152 602 (CCPA 1967).

It is sufficient that the reference(s) clearly suggest doing what the applicant(s) have done. In re Gershon 152 USPQ 602.

In addition, specific thickness of contaminated coating layer as claimed is taken to be obvious since these are variables of art recognized importance which are subject to routine experimentation and optimization and discovery of an optimum value for a known process is obvious. In re Aller, 105 USPQ 233 (CCPA 1955). And, even if applicants' modification results in great improvement and utility over the prior art, it may still not be patentable if the modification was within the capabilities of one skilled in the art, In Re Sola 25 USPQ 433.

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#### Conclusion

8. The prior art made of record and not relied upon is considered pertinent to applicant's disclosure. See PTOL-892.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Felisa Hiteshew whose telephone number is (571) 272-1463. The examiner can normally be reached on Mondays through Thursday from 5:30 AM to 4:00 PM with Fridays off.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Yogendra Gupta, can be reached on (571) 272-1316. The fax phone number for the organization where this application or proceeding is assigned is (571) 273-1463.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system. see

<a href="http://pair-direct.uspto.gov">http://pair-direct.uspto.gov</a>. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866- 217-9197 (toll-free).

<a href="http://pair-direct.uspto.gov">http://pair-direct.uspto.gov</a>. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866- 217-9197 (toll-free).

PRIMARY EXAMINER